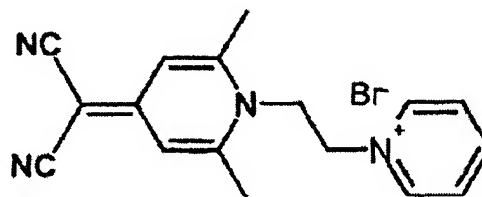
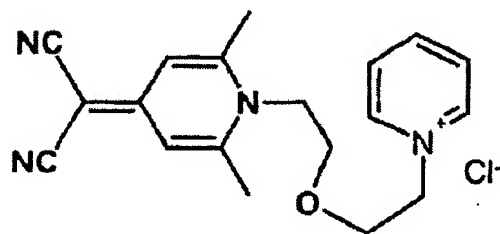
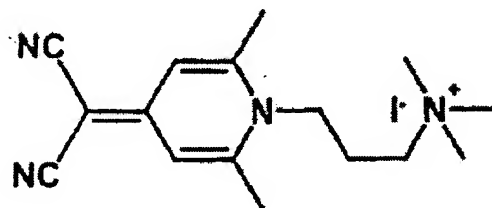
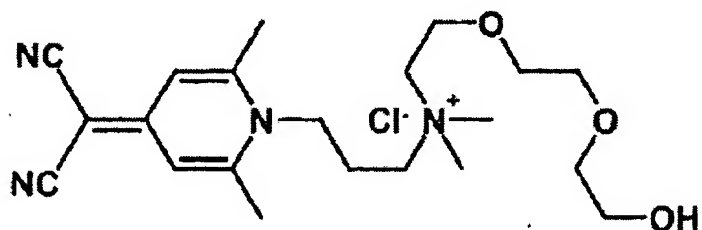
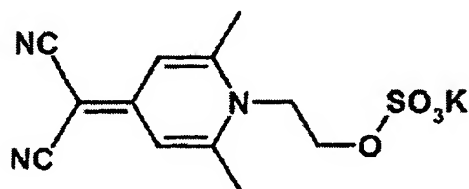
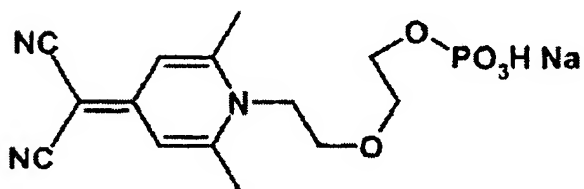


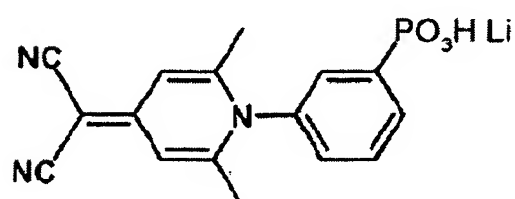
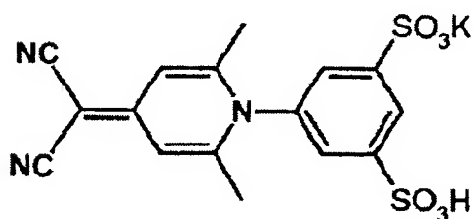
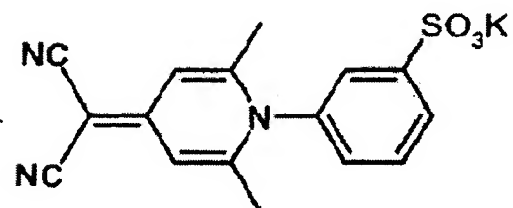
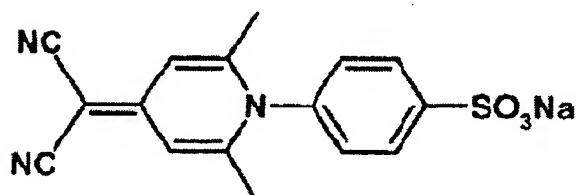
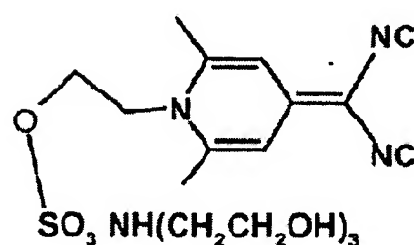
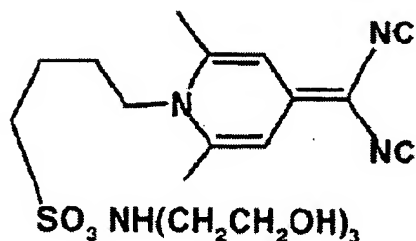
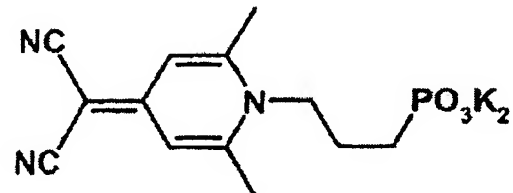
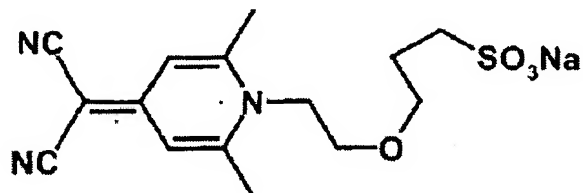
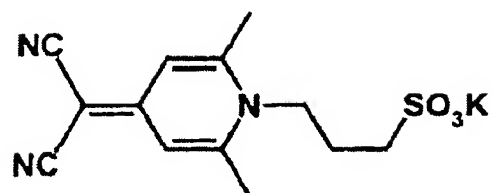
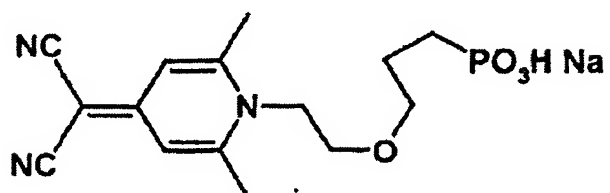
AMENDMENTS TO THE SPECIFICATION

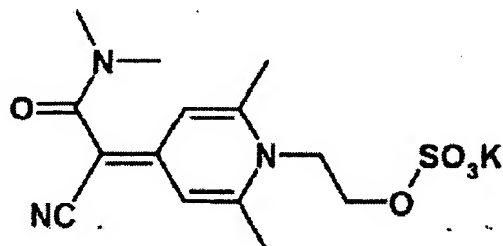
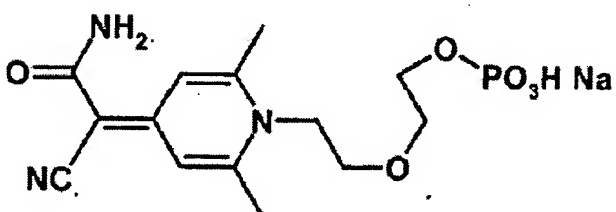
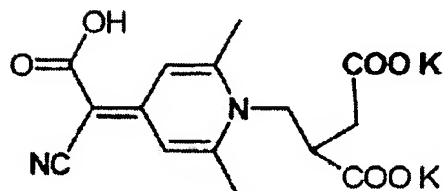
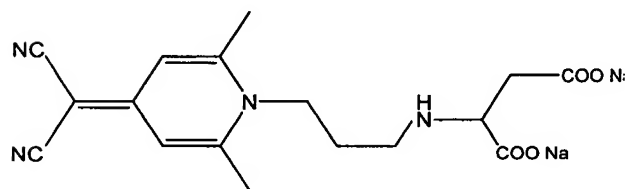
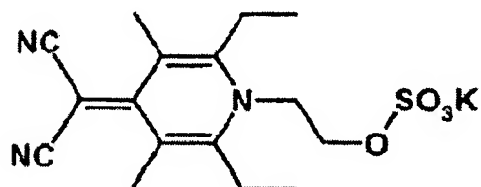
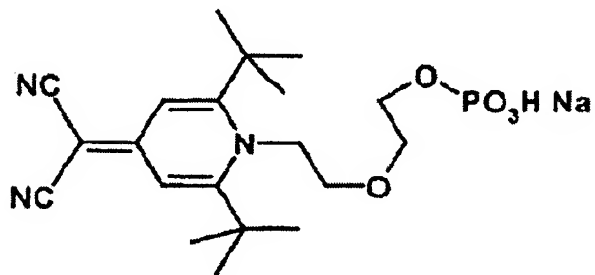
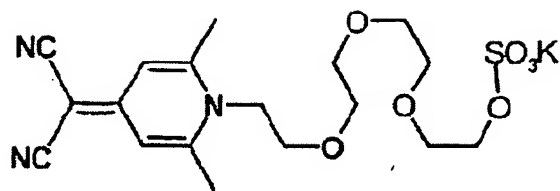
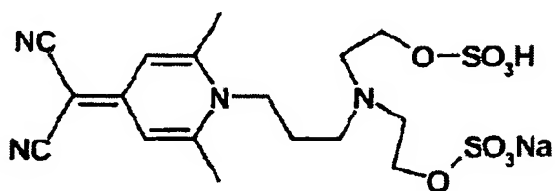
Please amend the Specification as follows:

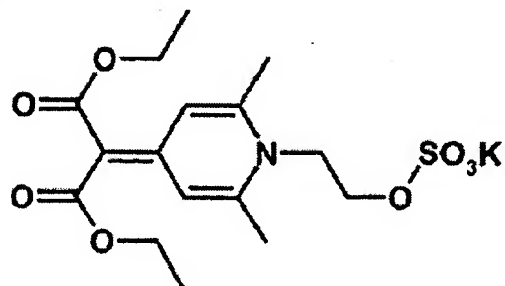
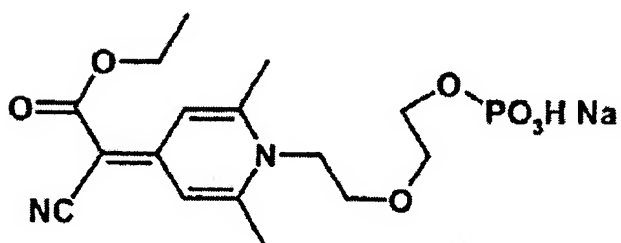
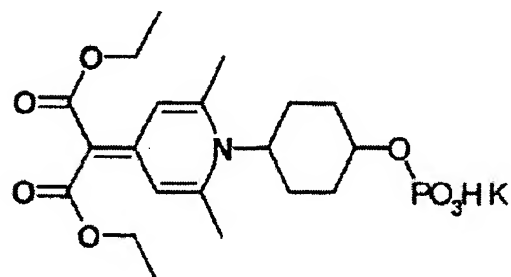
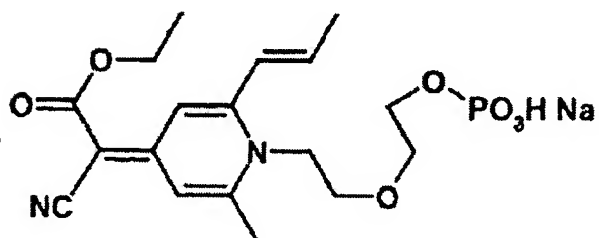
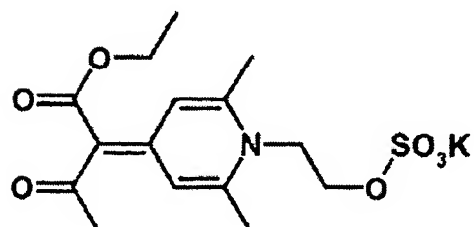
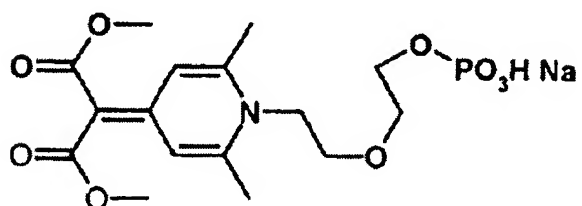
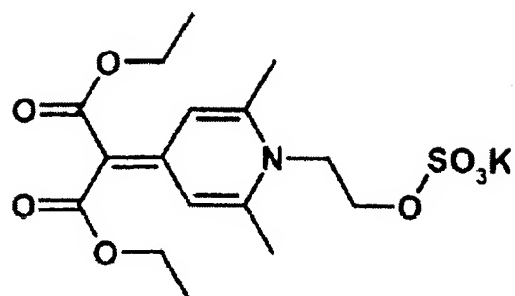
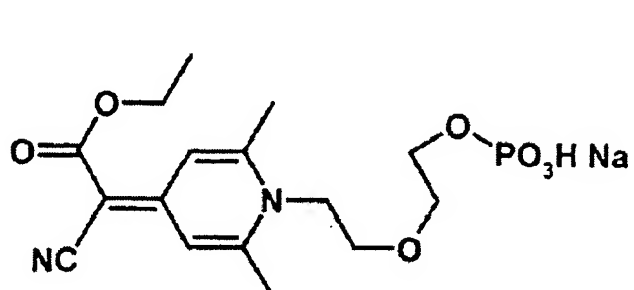
Please replace the paragraph from page 9, line 17 through page 13, line 2 (which corresponds to paragraph 37 of the published U.S. application), with the following amended paragraph:

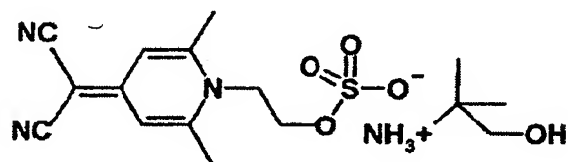
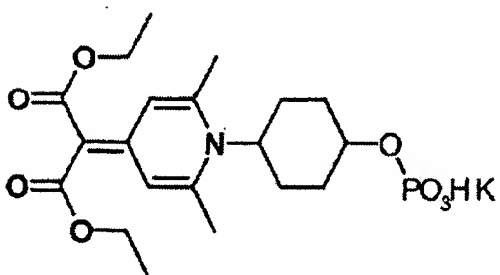
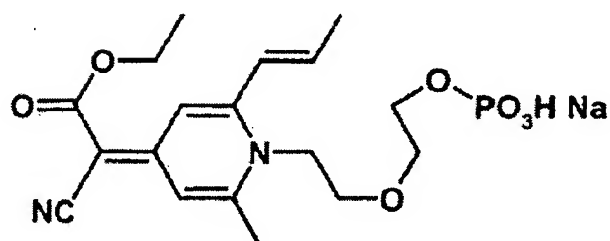
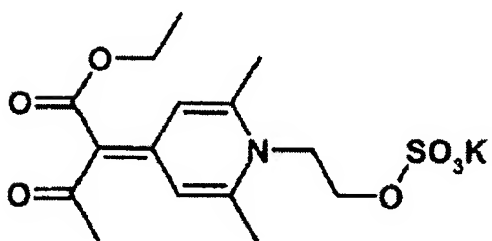
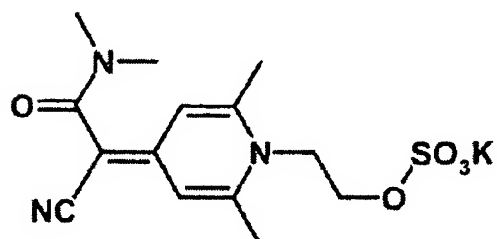
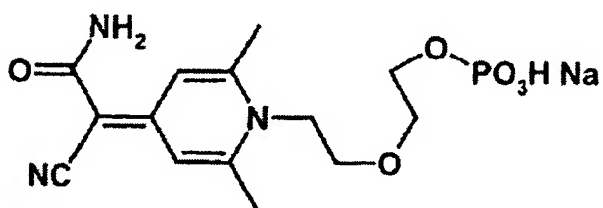
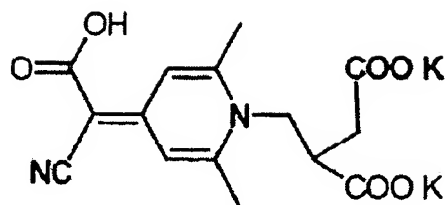
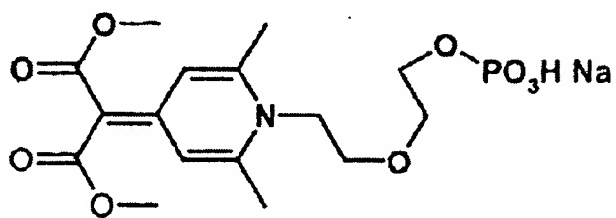
Preferred compounds of the present invention are

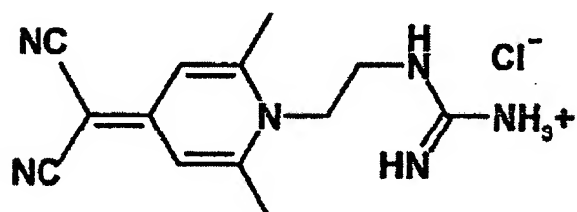
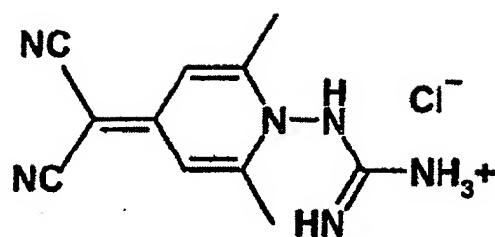
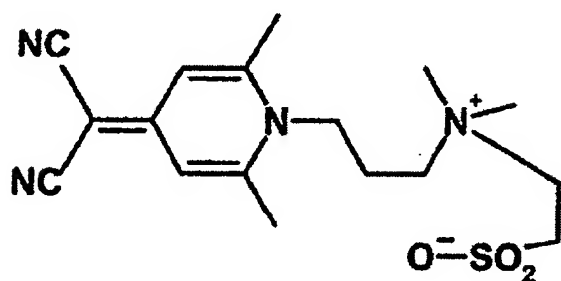










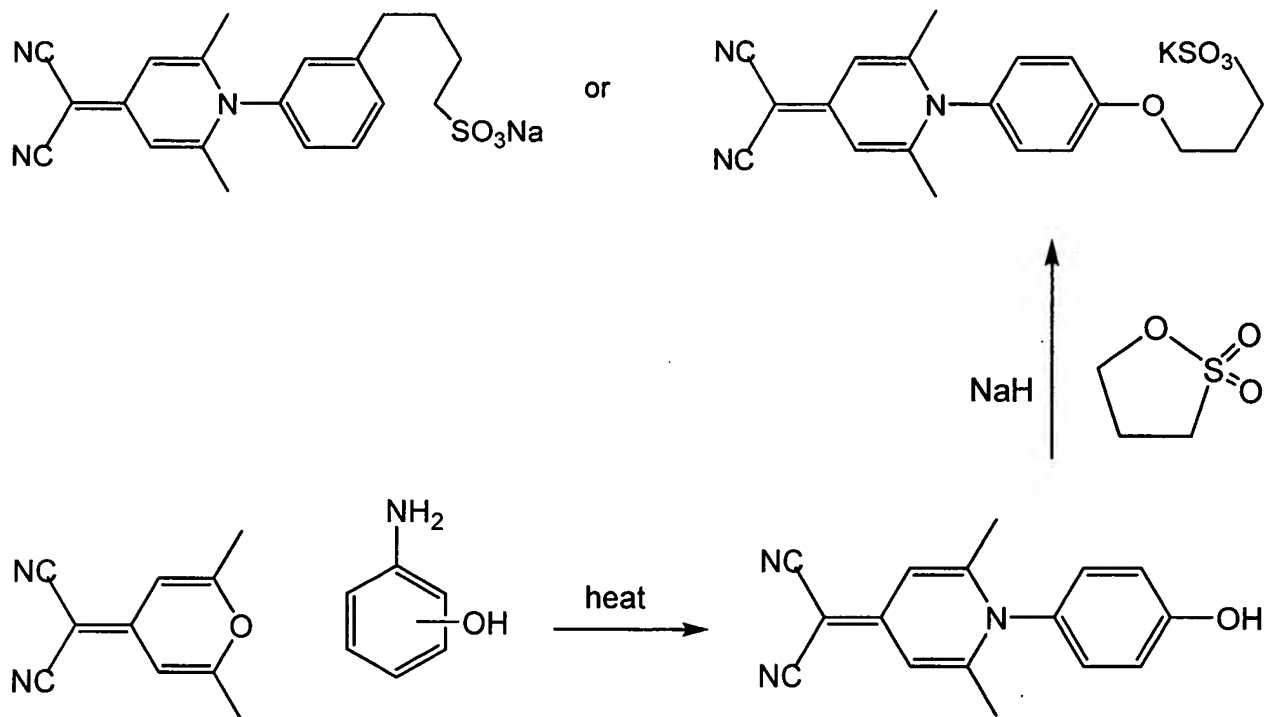


and combinations or interchangements of the varied structure elements.

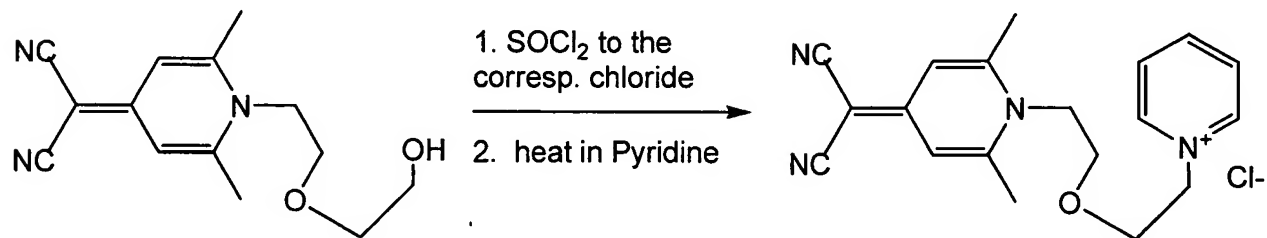
Please replace the paragraph from page 14, line 12 to the bottom of page 16 (which corresponds to the paragraph 41 of the published application), with the following amended paragraph:

Some further preferred compounds of the invention and general methods for their production are shown below:

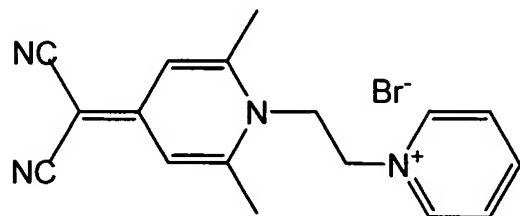
Process a)



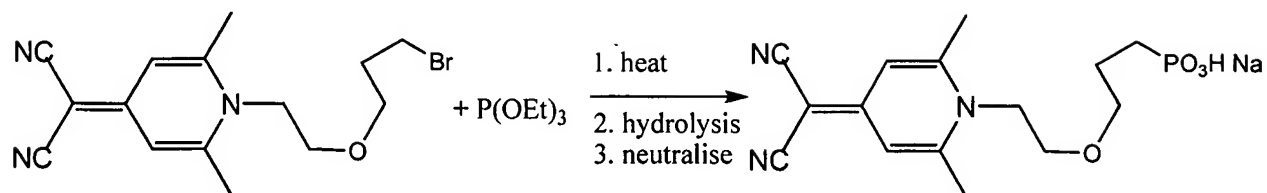
Process b)



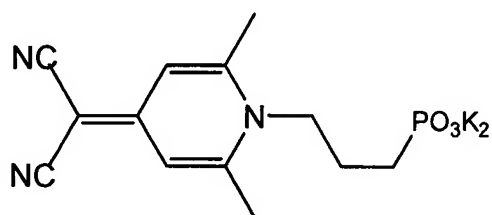
analogously to:



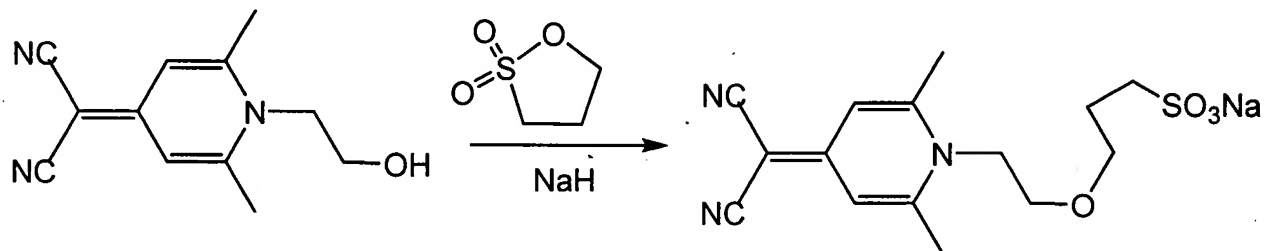
Process c)



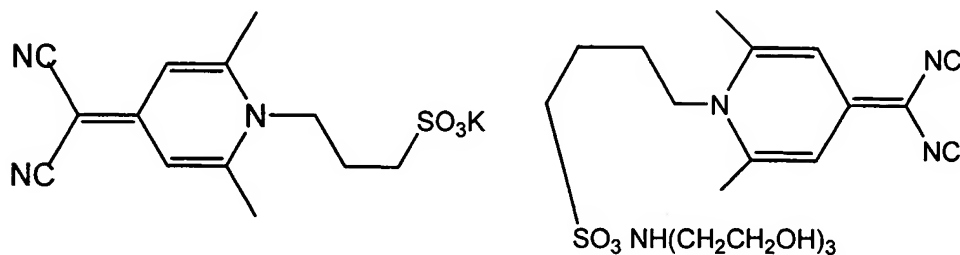
Analogously for



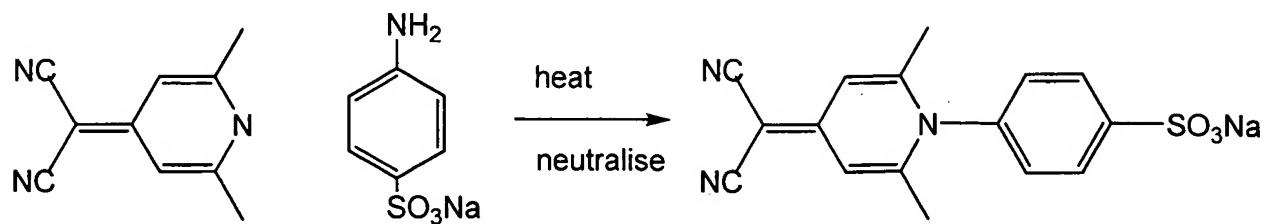
Process d)



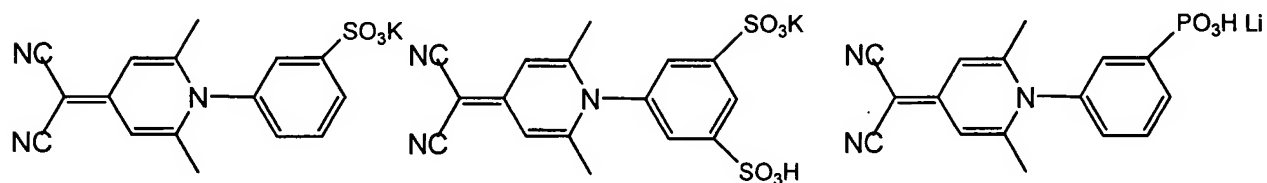
Analogously for:



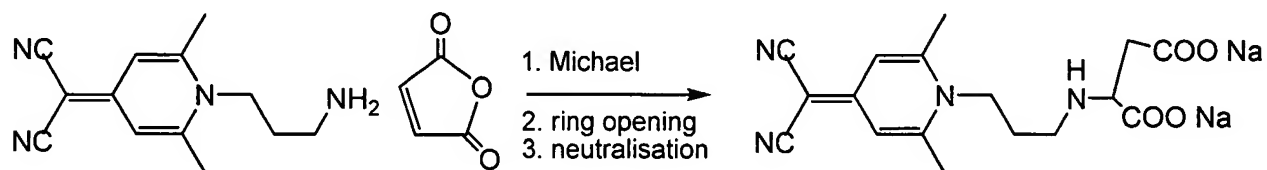
Process e)



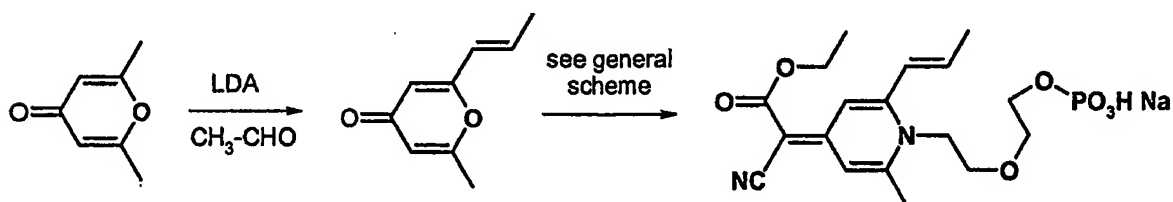
ditto for



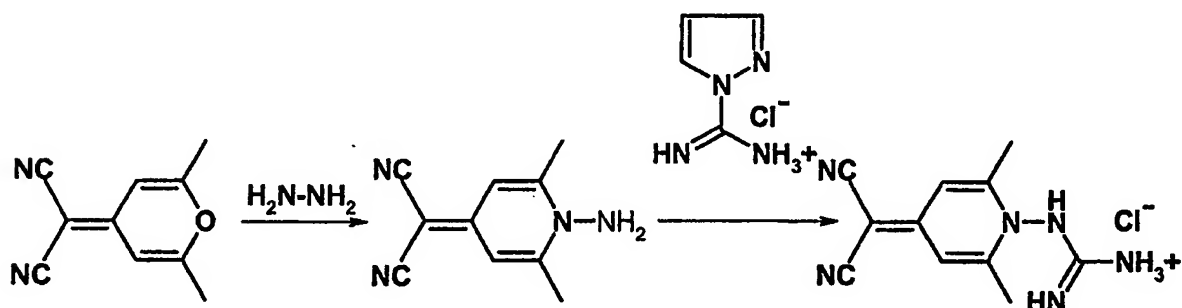
Process f)



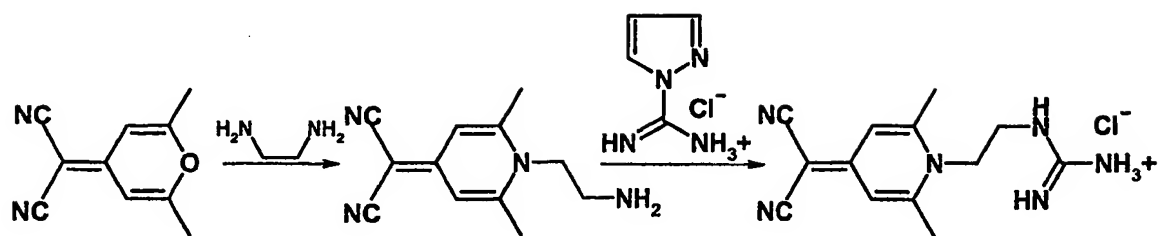
Process g)



Process h)



Process i)



Process j)

